UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

| APPLICATION NO.      | FILING DATE                         | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|----------------------|-------------------------------------|----------------------|---------------------|------------------|
| 10/840,240           | 05/07/2004                          | Jin-Ook Kim          | 053785-5182         | 7617             |
| , - <del>-</del>     | 7590 08/19/200<br>VIS & BOCKIUS LLP | _                    | EXAMINER            |                  |
| 1111 PENNSY          | LVANIA AVENUE N                     |                      | YI, STELLA KIM      |                  |
| WASHINGTON, DC 20004 |                                     |                      | ART UNIT            | PAPER NUMBER     |
|                      |                                     |                      | 1791                |                  |
|                      |                                     |                      |                     |                  |
|                      |                                     |                      | MAIL DATE           | DELIVERY MODE    |
|                      |                                     |                      | 08/19/2008          | PAPER            |

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

|  | Application No.   | Applicant(s)   |  |  |
|--|---|--|--|--|
|  | 10/840,240  | KIM, JIN-OOK   |  |  |
| Office Action Summary  | Examiner  | Art Unit   |  |  |
|  | Stella Yi   | 1791   |  |  |
| The MAILING DATE of this communication ap<br>Period for Reply  | opears on the cover sheet with the c  | correspondence address   |  |  |
| A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING ID.  - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period.  - Failure to reply within the set or extended period for reply will, by stature Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  | DATE OF THIS COMMUNICATION  .136(a). In no event, however, may a reply be tired will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE | N. nely filed the mailing date of this communication. D (35 U.S.C. § 133). |  |  |
| Status   |   |  |  |  |
| Responsive to communication(s) filed on <u>02 /</u> This action is <b>FINAL</b> . 2b) ☐ This action is <b>FINAL</b> .      Since this application is in condition for allowated closed in accordance with the practice under   | is action is non-final.<br>ance except for formal matters, pro  |  |  |  |
| Disposition of Claims  |   |  |  |  |
| 4)  Claim(s) 1-20 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5)  Claim(s) is/are allowed. 6)  Claim(s) 1-20 is/are rejected. 7)  Claim(s) is/are objected to. 8)  Claim(s) are subject to restriction and/  Application Papers 9)  The specification is objected to by the Examin  | awn from consideration.  For election requirement.  |  |  |  |
| 10) The drawing(s) filed on is/are: a) ac Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct  11) The oath or declaration is objected to by the E  | cepted or b) objected to by the edrawing(s) be held in abeyance. Section is required if the drawing(s) is ob  | e 37 CFR 1.85(a).<br>jected to. See 37 CFR 1.121(d).                       |  |  |
| Priority under 35 U.S.C. § 119   |   |  |  |  |
| <ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul> |   |  |  |  |
| Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO/SB/08)  Paper No(s)/Mail Date   | 4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:   | ate  |  |  |

Application/Control Number: 10/840,240 Page 2

Art Unit: 1791

## **DETAILED ACTION**

## Response to Amendment

1. Applicant's arguments, see Remarks, filed April 2, 2008, with respect to the rejection(s) of claim(s) 1-20 under LIN in view of XIA et al. have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of NISHIKAWA et al. in view of XIA et al.

## Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over NISHIKAWA et al. (6,063,527) and in further view of XIA et al. ("Soft Lithography." Angew. Chem. Int. Ed., 1998, pp.550-575).

Regarding claims 1-20, NISHIKAWA et al. discloses a method for making a color filter for a liquid crystal display device, comprising the steps of: Col.7, line 63 through Col.10, line 3:

(1) providing a removable mold 13 having an intaglio surface with a plurality of groove units formed therein, the groove units being arranged in predetermined pattern (Fig.1B);

Art Unit: 1791

- (2) attaching the removable mold to a transparent substrate, thereby the intaglio surface and the transparent substrate 10 cooperatively forming a plurality of channel units (Fig.1C);
- (3) injecting the said channel units with a photopolymer solution containing colorants (Col.11, lines 15-29);
- (4) the said groove units are separated by partition walls, and the groove units comprises three types of grooves which are injected with corresponding red-colored, green-colored, and blue-colored photopolymer sub-pixel solution, respectively (Col.11, lines 23-51);
- (5) applying an ultraviolet light to the said photopolymer solution through the transparent substrate 10 so as to cure the photopolymer to the transparent substrate (Col.9, lines 52-63; Fig.1C); and
- (6) removing the removable mold with the patterned photopolymer layer formed on the transparent substrate (Fig.1D).

Steps (1) and (6) corresponds to instant claims 1, 11, and 16 where a removable mold with grooves is being used. Steps (2)-(4) corresponds with instant claims 2, 11, and 16 where channels of the mold are filled with color resin. Step (5) corresponds with instant claims 3, 13, 16, and 19 where curing each of the color resin in the sub-color filters are done by irradiating light which gives off heat. In addition to instant claim 16, it is known to one of ordinary skill in the art that color liquid crystal display devices include an active matrix substrate on which a plurality of active elements are formed, a color filter substrate on which color filter layers of different colors and a common electrode

are deposited in this order. Regarding claim 8, the said method further comprises forming a black matrix over the said substrate (Col.5, lines 60-63).

LIN does not appear to explicitly disclose using three molds or using the onemold multiple times, made of polydimethylsiloxane (PDMS) to form the color filter where the channels are filled with color resin by capillary action.

However, XIA et al. discloses a polydimethylsiloxane (PDMS) mold having relief structures that form a network of empty channels to be filled with a liquid prepolymer by capillary action. This is a soft lithography method known as "micromolding in capillaries". The steps of this method is illustrated in Figure 1 below (XIA et al. p.562):

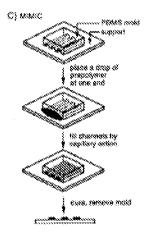


Figure 1

This method corresponds to instant claims 1, 5, 6, 10, 11, 14, and 16. In view of XIA et al.'s method of micromolding in capillaries, it would have been obvious to one of ordinary skill in the art to use the PDMS mold three times or use three PDMS molds in order to form three different sub-color filters with three differenct color resins, as required by NISHIKAWA et al.

Art Unit: 1791

The PDMS mold is an elastomer. The elasticity and low surface energy of the PDMS mold allows it to be detached easily from surfaces. It is also optically transparent down to about 300 nm in order to allow UV light to cure resin (XIA et al. pp.556, 562). This corresponds to instant claims 3, 4, 11, 12, 13, 17, 18, and 19. Also, the elastomeric mold offers the opportunity to manipulate the size and shape of features present on the mold so as to give different shapes to the injected resin or polymer in the mold such as a stripe shape. The cured polymers, therefore, possess almost the exact dimensions and shapes of the channels in the surface of the PDMS mold (XIA et al. p.567). This corresponds to instant claims 7 and 15.

Page 5

NISHIKAWA et al. and XIA et al. are analogous art because they are from the same field of endeavor, that is microfabrication technology. At the time of the invention, one of ordinary skill in the art would have been motivated to modify the method of forming color filters for liquid crystal display devices of NISHIKAWA et al. to include the micromolding in capillaries method from XIA et al. because XIA et al. suggests that the use of soft lithography may be practical from display devices and that patterning techniques such as micromolding in capillaries have potential for application in emerging technologies or in high-resolution patterning (XIA et al. p.570). XIA et al.'s purpose for developing the use of soft lithography/micromolding in capillaries for the technology of microfabrication is to provide a convenient and inexpensive method to pattern small or large surfaces of substrates. The object of NISHIKAWA et al. invention is to provide a method for making a color filter for use in a liquid crystal display, which is simple and has a minimized manufacturing cost (Col.1, lines 5-7; Col.3, lines 6-15). XIA

Application/Control Number: 10/840,240 Page 6

Art Unit: 1791

et al. suggests the method for liquid crystal displays and patterning, and NISHIKAWA et al. provides a display with a patterned layer. Therefore, the method of forming color filter layer for liquid crystal display device in instant claims 1-20 would have been obvious at the time the invention was made.

## Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stella Yi whose telephone number is 571-270-5123. The examiner can normally be reached on Monday - Thursday from 8:00 AM to 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Christina Johnson can be reached on 571-272-1176. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/840,240

Page 7

Art Unit: 1791

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

SY

/Christina Johnson/

Supervisory Patent Examiner, Art Unit 1791